$(2/2)$

計畫主持人: 劉晉良

報告類型: 完整報告

。
在前書 : 本計畫可公開查

行政院國家科學委員會專題研究計畫 成果報告

93 12 6

YJCPH 668 No. of Pages 26, DTD = 5.0.1

Available online at www.sciencedirect.com

Journal of Computational Physics xxx (2004) xxx–xxx

JOURNAL OF COMPUTATIONAL PHYSICS

A quantum corrected energy-transport model for nanoscale semiconductor devices www.elsevier.com/locate/jcp
del for

4 Ren-Chuen Chen, Jinn-Liang Liu *

5 Department of Applied Mathematics, National Chiao Tung University, 1001 Ta Hsueh Road, Hsinchu 300, Taiwan

Received 29 June 2004; received in revised form 4 October 2004; accepted 4 October 2004

8 Abstract

2

3

A quantum corrected energy-transport model for
manoscale semiconductor devices
 ϵ Ren-Chuen Chen, Jinn-Liang Liu
 ϵ
 P_{opt0} and ϵ q_{opt0} and ϵ q_{opt0} and ϵ q_{opt0} and ϵ ϵ ϵ ϵ ϵ $\$ An energy transport model coupled with the density gradient method as quantum mechanical corrections is pro- posed and numerically investigated. This new model is comprehensive in both physical and mathematical aspects. It is capable of describing hot electron transport as well as significant quantum mechanical effects for advanced devices with dimensions comparable to the de Broglie wave-length. The model is completely self-adjoint for all state variables and hence provides many appealing mathematical features such as global convergence, fast iterative solution, and highly parallelizable. Numerical simulations on diode and MOSFET with the gate length down to 34 nm using this 15 model have been performed and compared with that using the classical transport model. It is shown that the $I-V$ char- acteristics of this short-channel device is significantly corrected by the density-gradient equations with current drive reduced by up to 60% comparing with that of the classical model along. Moreover, a 2D quantum layer, which is only a fraction of the length scale of inversion layer, is also effectively captured by this new model with very fine mesh near the interface produced by an adaptive finite element method. \odot 2004 Published by Elsevier Inc.

21

22 1. Introduction

23 Numerical simulation of charge transport in device structures is widely used for analysis of physical 24 processes in the semiconductor devices and estimation of their electrical parameters. The major part of 25 the activities in this field is based on drift-diffusion (DD) equations. However, there is a growing realization 26 that technologist cannot ignore quantum effects much longer. The combination of thin gate oxides and hea-

27 vy doping in the conventional MOSFETs, and the thin silicon body of the double-gate structures, will result

28 in substantial quantum mechanical (QM) threshold voltage shift and transconductance degradation [21].

Corresponding author. E-mail address: jinnliu@math.nctu.edu.tw (J.-L. Liu).

^{0021-9991/\$ -} see front matter © 2004 Published by Elsevier Inc. doi:10.1016/j.jcp.2004.10.006

23 October 2004; Disk Used

2 R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx

29 Computationally efficient methods to include QM effects are required for the purpose of practical Compu-30 ter Aided Design of this generation of devices.

31 Some numerical methods employing full quantum models such as non-equilibrium Green's function [23] 32 and Wigner's function [9] suffer from unsolved robustness problems and are still much too costly for device 33 or circuit simulations. Another approach for including QM effects is to add quantum corrections to clas-34 sical models [4,3,15–20,22,28,30,32,33]. In particular, the density gradient (DG) model developed by Anc-35 ona et al. is a more rigorous macroscopic transport model which avoids ad hoc assumption to the material 36 parameters or imposing an artificial shape function [34]. It is demonstrated in [1,7,8,29] that this model is 37 feasible and efficient to accurately and generally simulate multi-dimensional devices with gate lengths rang-38 ing from 30 nm down to 6 nm when combined with the DD model.

39 In this paper, we further extend the DG model to combine with the energy transport (ET) model pro-40 posed in our previous work [11] and show that this new combination (DGET) is capable of describing hot 41 electron transport as well as significant QM effects for advanced devices. Our model is able to explain that 42 electron temperature essentially differs from the lattice temperature. It is clear that this effect cannot be de-43 scribed by the DG model along. Quantum hydrodynamic (QHD) models give accurate simulation results, 44 but the numerical methods to solve this system are too costly and time consuming to model real problems in 45 semiconductor production mode where simulation results are needed in hours or minutes. The DGET mod-46 el is of parabolic type so that its numerical solution needs less effort than QHD models which contain 47 hyperbolic modes.

In where stundard part remains the part remains probable and a test mumer in o couply of access
a consideration (a) such that is a consider the coupling of th 48 Moreover, our model is completely self-adjoint for all state variables and hence provides many appealing 49 mathematical features such as global convergence, fast iterative solution, and highly parallelizable as dem-50 onstrated in our previous papers [11,12,24]. The global convergence is a consequence of monotone iterative 51 methods used in solving the discrete systems of nonlinear algebraic equations resulting from adaptive finite 52 element approximation of the model. It is shown here that the convergence analysis of these methods given 53 in [11,12] can be straightforwardly carried over to the present model. Our numerical experiments on various 54 device structures with high drain bias have shown that the monotone iteration do not suffer from the con-55 vergence difficulties as frequently encountered by the commonly used Newton's iteration since the Jacobian 56 is either close to singular or poorly conditioned [29]. This is a fundamental issue constantly faced by the 57 practitioner in device and circuit modeling. Numerical simulations on diode and MOSFET with the gate 58 length down to 34 nm using the DGET model have been performed and compared with that using the 59 ET model. It is shown that the $I-V$ characteristics of this short-channel device is significantly corrected 60 by the density-gradient equations with current drive reduced by up to 60% compared with that of the clas-61 sical model along. Moreover, a 2D quantum layer, which is only a fraction of the length scale of inversion 62 layer, is also effectively captured by this new model with very fine mesh near the interface produced by the 63 adaptive finite element method.

64 The paper is divided into the following sections: Section 2 briefly recalls the ET model considered in [11] 65 and the DG model. A full self-adjoint formulation of both models is then given in Section 3. For the sake of 66 clearness, we also extend our previous adaptive finite-element algorithm [11] to the present model in Section 67 4. In Section 5, numerical results of simulation on various diodes to compare with the results in the liter-68 ature and on MOSFET device structures to demonstrate the effectiveness of the proposed model. A short 69 concluding remark is given in Section 6.

70 2. The energy transport and density gradient models

71 As in [11], we consider the following ET model

$$
\Delta \phi = \frac{q}{\varepsilon_{\rm s}} (n - p + N_{\rm A}^- - N_{\rm D}^+),\tag{1}
$$

ARTICLE IN PRESS

1 $\frac{1}{q}\nabla$. $\cdot \mathbf{J}_n = R,$ (2) 1 $\frac{1}{q}\nabla \cdot \mathbf{J}_{\mathrm{p}} = -R,$ (3) $\nabla \cdot \mathbf{S}_\mathrm{n} = \mathbf{J}_\mathrm{n} \cdot \mathbf{E} - n \left(\frac{\omega_\mathrm{n} - \omega_\mathrm{0}}{\sigma_{\text{n}}} \right)$ $\tau_{\mathrm{n}\omega}$ \sqrt{a} \sqrt{a} $\hspace{0.1cm}$, (4) $\nabla \cdot {\bf S}_{\rm p} = {\bf J}_{\rm p} \cdot {\bf E} - p \biggl(\frac{\omega_{\rm p} - \omega_0}{\tau}$ $\tau_{\rm p\omega}$ \sqrt{a} \sqrt{a} $\hspace{1.5cm}$, (5) R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx 3

 $\frac{1}{q}\nabla \cdot \mathbf{J}_p = -R,$ (3)
 $\nabla \cdot \mathbf{S}_p = -\mathbf{J}_p \cdot \mathbf{E} - p\left(\frac{\omega_0 - \omega_0}{\tau_{\text{top}}}\right),$ (4)

bere ψ is the electrostatic rotential *n* and *p* are the electron and bolic osticentrations, *n* is the element-

pointing 87 where ϕ is the electrostatic potential, *n* and *p* are the electron and hole concentrations, *q* is the elemen-88 tary charge, ε_s is the permittivity constant of semiconductor, N_A^- and N_D^+ are the densities of ionized 89 impurities, J_n and J_p are the current densities, R is the function describing the balance of generation 90 and recombination of electrons and holes, S_n and S_p are the energy fluxes for carriers, E is the electric 91 field, $\tau_{n\omega}$ and $\tau_{p\omega}$ are the carrier energy relaxation times, ω_0 is the thermal energy, and ω_n and ω_p are 92 the carrier average energies. These physical variables are tightly coupled together with the following aux-93 iliary relationships

$$
\mathbf{E} = -\nabla \phi,\tag{6}
$$

$$
\mathbf{J}_{n} = -q\mu_{n}n\nabla\phi + qD_{n}\nabla n = -qn\mathbf{v}_{n},\tag{7}
$$

$$
\mathbf{J}_{\mathrm{p}} = -q\mu_{\mathrm{p}}p\nabla\phi - qD_{\mathrm{p}}\nabla p = qp\mathbf{v}_{\mathrm{p}},\tag{8}
$$

$$
\mathbf{S}_n = \frac{\mathbf{J}_n}{-q} \omega_n + \frac{\mathbf{J}_n}{-q} k_B T_n + \mathbf{Q}_n, \tag{9}
$$

$$
\mathbf{S}_{\mathrm{p}} = \frac{\mathbf{J}_{\mathrm{p}}}{+q} \omega_{\mathrm{p}} + \frac{\mathbf{J}_{\mathrm{p}}}{+q} k_{\mathrm{B}} T_{\mathrm{p}} + \mathbf{Q}_{\mathrm{p}},\tag{10}
$$

$$
\omega_0 = \frac{3}{2} k_B T_L,\tag{11}
$$

$$
\omega_{\rm n} = \frac{3}{2} k_{\rm B} T_{\rm n} + \frac{1}{2} m_{\rm n}^* |\mathbf{v}_{\rm n}|^2, \tag{12}
$$

$$
\omega_{\rm p} = \frac{3}{2} k_{\rm B} T_{\rm p} + \frac{1}{2} m_{\rm p}^* |{\bf v}_{\rm p}|^2, \tag{13}
$$

$$
\mathbf{Q}_n = -\kappa_n \nabla T_n,\tag{14}
$$

$$
\mathbf{Q}_{\mathrm{p}} = -\kappa_{\mathrm{p}} \nabla T_{\mathrm{p}},\tag{15}
$$

$$
\kappa_{\rm n} = 2\left(\frac{k_{\rm B}}{q}\right)^2 n q \mu_{\rm n} T_{\rm L},\tag{16}
$$

$$
\kappa_{\rm p} = 2 \left(\frac{k_{\rm B}}{q}\right)^2 p q \mu_{\rm p} T_{\rm L},\tag{17}
$$

ARTICLE IN PRESS

4 R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx

$$
R = \frac{np - n_1^2}{\tau_n^0 (p + p_\text{T}) + \tau_p^0 (n + n_\text{T})},\tag{18}
$$

126 where Q_n and Q_p are the heat fluxes for carries, k_B is Boltzmann's constant, T_n , T_p , and T_L are the electron, 127 hole and lattice temperatures, μ_n and μ_p are the field-dependent electron and hole mobilities, D_n and D_p are 128 the electron and hole diffusion coefficients expressed by the Einstein relation with the mobilities, m_n^* and m_p^* 129 are the electron and hole effective masses, v_n and v_p are the electron and hole velocities, κ_n and κ_p are the 130 electron and hole heat conductivities, and (18) is the Shockley–Read–Hall (SHR) generation-recombination 131 model with n_i being the intrinsic carrier concentration, τ_n^0 and τ_p^0 the electron and hole lifetimes, and p_T and 132 n_T the electron and hole densities associated with energy levels of the traps. In the above equations, vectors 133 are denoted by bold letters.

134 The DG theory was developed by observing that the electron gas is energetically sensitive not only to its 135 density but also to the gradient of the density. It captures the nonlocality of quantum mechanics to the low-136 est-order of \hbar^2 where \hbar is the reduced Planck constant and can be rigorously derived from quantum 137 mechanics [4,3]. Specifically, a third order derivative term of quantum correction is added to the carrier cur-138 rent density as

$$
\mathbf{J}_{n} = -q\mu_{n}n\nabla\phi + qD_{n}\nabla n - 2q\mu_{n}b_{n}n\nabla\left[\frac{\Delta\sqrt{n}}{\sqrt{n}}\right],
$$
\n(19)

$$
\mathbf{J}_{\mathrm{p}} = -q\mu_{\mathrm{p}}p\nabla\phi - qD_{\mathrm{p}}\nabla p + 2q\mu_{\mathrm{p}}b_{\mathrm{p}}p\nabla\left[\frac{\Delta\sqrt{p}}{\sqrt{p}}\right],\tag{20}
$$

Fig. 1. The numerical results of the 600 nm silicon diode.

ARTICLE IN PRESS

R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx 5

145 where the coefficients $b_n = \frac{\hbar^2}{12m_p^*q}$ and $b_p = \frac{\hbar^2}{12m_p^*q}$ are the material parameters measuring the strength of the 146 gradient effects in the gas. To alleviate the difficulty in discretization caused by this higher order term, addi-147 tional variables called the quantum potentials

$$
\phi_{qn} \equiv 2b_n \left[\frac{\Delta \sqrt{n}}{\sqrt{n}} \right],
$$
\n
$$
\phi_{qp} \equiv -2b_p \left[\frac{\Delta \sqrt{p}}{\sqrt{p}} \right]
$$
\n(21)

154 have been introduced in [29] and thus can be lumped with the classical drift term to obtain

$$
\mathbf{J}_{n} = -q\mu_{n}n\nabla(\phi + \phi_{qn}) + qD_{n}\nabla n, \tag{23}
$$

$$
\mathbf{J}_{\mathrm{p}} = -q\mu_{\mathrm{p}}p\nabla(\phi + \phi_{\mathrm{qp}}) - qD_{\mathrm{p}}\nabla p. \tag{24}
$$

160 We thus have a complete set of seven PDEs (1)–(5) and (21) and (22) describing both ET and DG models 161 with the seven state variables ϕ , *n*, *p*, ϕ_{qn} , ϕ_{qp} , *T*_n, and *T*_p.

162 Note that the coefficients in (21) and (22) result in a boundary layer near the silicon/silicon-oxide interface

163 for short-channel devices. The layer is only a fraction of the length scale of the inversion layer, in which the

164 electron density typically drops from its peak value of order 10^{18} at about 0.5–1.5 nm away from the interface

165 to zero at the interface [1,7]. Numerical treatments for this boundary layer problem are evidently subtle and

166 challenging. A more detailed description of our approach to this problem will be given in Section 5.

Fig. 2. The numerical results of the 120 nm silicon diode.

6 R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx

167 Remark 2.1. Taking first three moments of the Boltzmann transport equation (BTE) with conservation of 168 particles, momentum, and energy, the classical hydrodynamic (CHD) model can be expressed as (for 169 simplicity, we list the equations of electrons only) [6,17]:

$$
\begin{aligned}\n\frac{\partial n}{\partial t} + \nabla \cdot (n\mathbf{v}_n) &= \left(\frac{\partial n}{\partial t}\right)_c, \\
\frac{\partial \mathbf{p}_n}{\partial t} + \mathbf{v}_n \nabla \cdot \mathbf{p}_n + \mathbf{p}_n \cdot \nabla \mathbf{v}_n &= -qn\mathbf{E} - \nabla(nk_B T) + \left(\frac{\partial \mathbf{p}_n}{\partial t}\right)_c, \\
\frac{\partial \omega_n}{\partial t} + \nabla \cdot (\mathbf{v}_n \omega_n) &= -qn\mathbf{v}_n \cdot \mathbf{E} - \nabla \cdot (\mathbf{v}_n n k_B T) - \nabla \cdot \mathbf{Q}_n + \left(\frac{\partial \omega_n}{\partial t}\right)_c,\n\end{aligned}
$$

172 where $\mathbf{p}_n = m_n^* m_n$ is the momentum density. Considering the steady state and employing the collision terms

$$
\begin{aligned}\n&\left(\frac{\partial \mathbf{p}_n}{\partial t}\right)_c = -\frac{\mathbf{p}_n}{\tau_{pn}},\\
&\left(\frac{\partial \omega_n}{\partial t}\right)_c = -\frac{\omega_n - \omega_0}{\tau_{n\omega}},\n\end{aligned}
$$

175 we have [11]

$$
\mathbf{J}_{n} = q\mu_{n} \left[\frac{k_{\mathrm{B}}T_{n}}{q} \nabla n + n \nabla \left(\frac{k_{\mathrm{B}}T_{n}}{q} - \phi \right) \right]
$$

178 and Eq. (4). Similarly the three conservation equations of the QHD model are [16,18]

Fig. 3. The numerical results of the 30 nm silicon diode.

R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx 7

$$
\frac{\partial n}{\partial t} + \nabla \cdot (n\mathbf{v}_n) = \left(\frac{\partial n}{\partial t}\right)_c,
$$
\n
$$
\frac{\partial \mathbf{p}_n}{\partial t} + \mathbf{v}_n \nabla \cdot \mathbf{p}_n + \mathbf{p}_n \cdot \nabla \mathbf{v}_n + \frac{n}{3} \nabla Q = -qn\mathbf{E} - \nabla (nk_B T) + \left(\frac{\partial \mathbf{p}_n}{\partial t}\right)_c,
$$
\n
$$
\frac{\partial \omega_n}{\partial t} + \nabla \cdot (\mathbf{v}_n \omega_n) = -qn\mathbf{v}_n \cdot \mathbf{E} - \nabla \cdot (\mathbf{v}_n nk_B T) - \nabla \cdot \mathbf{Q}_n + \left(\frac{\partial \omega_n}{\partial t}\right)_c.
$$

181 The quantum correction to the momentum equation is related to the quantum potential of Bohm [27]

$$
Q=-\frac{\hbar^2}{2m_{\rm n}^*}\frac{\Delta\sqrt{n}}{\sqrt{n}},
$$

23 October 2004; Disk Used

184 and to the energy density given by

$$
\omega_{\rm n} = \frac{3}{2} k_{\rm B} T_{\rm n} + \frac{1}{2} m_{\rm n}^* |{\bf v}_{\rm n}|^2 - \frac{\hbar^2 n}{24 m_{\rm n}^*} \Delta \log(n).
$$

187 Following the previous deductive procedure the quantum correction current density equation is

$$
\mathbf{J}_{\mathbf{n}} = q\mu_{\mathbf{n}} \left[\frac{k_{\mathbf{B}}T_{\mathbf{n}}}{q} \nabla n + n \nabla \left(\frac{k_{\mathbf{B}}T_{\mathbf{n}}}{q} - \phi \right) - \frac{\hbar^2}{6m_{\mathbf{n}}^*q} \nabla \left(\frac{\Delta \sqrt{n}}{\sqrt{n}} \right) \right]
$$

= $-q\mu_{\mathbf{n}} n \nabla (\phi + \phi_{\mathbf{q}\mathbf{n}}) + qD_{\mathbf{n}} \nabla n + \mu_{\mathbf{n}} k_{\mathbf{B}} n \nabla T_{\mathbf{n}}.$

Fig. 4. The tendency of the quantum potential variation.

8 R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx

190 Compared to the DG model, there is a mechanism that can cause an increase in diffusion, i.e., particle 191 diffusion is enhanced when T_n is significantly greater than T_L . Once we obtain the information of T_n from 192 the DGET model, we will use this formulation to estimate the drain current and to sketch the I–V curves. 193 On the other hand, since we do not add the quantum correction to the energy density, the difference of the 194 temperature distribution between the ET and DGET models is not very significant.

195 Remark 2.2. A quantum energy balance model appears to be first proposed by Grubin and Kreskovsky in 196 [18] for 1D mesoscopic structures. In their model, quantum correction terms are explicitly included in the 197 carrier average energies (11) and (12). As a result, third order derivative terms of correction are associated 198 not only with the carrier densities (see (19) and (20)) but also with the carrier energies. Putting these cor-199 rection terms into our model, i.e. into (9) and (10), we will obtain a product of the correction terms in (9) 200 and (10) which obviously makes computations more formidable for 2D simulation. Instead, the correction 201 terms in our model are only explicitly added to the carrier density. The energy balance equations are implic-202 itly and thus less corrected by the quantum effects via the carrier current densities.

203 3. A self-adjoint formulation of the DGET model

204 PDEs in self-adjoint form are analytically as well as numerically appealing. In [11,12], we give a rather 205 thorough study of the self-adjoint DD and ET models in terms of mathematical analysis and numerical jus-206 tification. We now consider the self-adjoint formulation of the above DGET model and, for this purpose,

207 introduce the following new variables

Fig. 5. Doping concentration.

ARTICLE IN PRESS

R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx 9

$$
u = \exp\left(\frac{-\varphi_n}{V_T}\right),
$$
\n
$$
v = \exp\left(\frac{\varphi_p}{V_T}\right),
$$
\n
$$
\zeta_n = \sqrt{n},
$$
\n
$$
\zeta_p = \sqrt{p},
$$
\n
$$
g_n = T_n / \exp\left(\frac{5\varphi_n}{4V_T}\right),
$$
\n
$$
g_p = T_p / \exp\left(-\frac{5\varphi_p}{4V_T}\right),
$$
\n(30)

221 where $V_T = (k_B T_L)/q$ is the thermal voltage and φ_n and φ_p are the generalized quasi-Fermi potentials that 222 include the QM effects as shown below. Assuming a Maxwell–Boltzmann energy distribution of carriers, we 223 have the quantum correction expressions of the carriers

Fig. 6. The final adaptive mesh.

YJCPH 668
ARTICLE IN PRESS No. of Pages 26, DTD=5.0.1

10 **R.-C.** Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx

$$
n = n_{\rm i} \exp\left(\frac{\phi - \varphi_{\rm n} + \phi_{\rm qn}}{V_{\rm T}}\right) = n_{\rm i} \exp\left(\frac{\phi + \phi_{\rm qn}}{V_{\rm T}}\right)u = \zeta_{\rm n}^2,\tag{31}
$$

$$
p = n_{\rm i} \exp\left(\frac{\varphi_{\rm p} - \phi - \phi_{\rm qp}}{V_{\rm T}}\right) = n_{\rm i} \exp\left(\frac{-\phi - \phi_{\rm qp}}{V_{\rm T}}\right) v = \zeta_{\rm p}^2,\tag{32}
$$

229 and rewrite the quantum potentials as

$$
\phi_{qn} = V_T \ln \left(\frac{\zeta_n^2}{u n_i} \right) - \phi,
$$
\n
$$
\phi_{qp} = -V_T \ln \left(\frac{\zeta_p^2}{v n_i} \right) - \phi.
$$
\n(33)

234 For Eq. (1) we have

$$
\Delta \phi = F(\phi, u, v, \zeta_n, \zeta_p),\tag{35}
$$

237 where

$$
F(\phi, u, v, \zeta_n, \zeta_p) = \frac{qn_i}{\varepsilon_s} \left[u \exp\left(\frac{\phi + \phi_{qn}}{V_T}\right) - v \exp\left(\frac{-\phi - \phi_{qp}}{V_T}\right) \right] + \frac{q(N_A^- - N_D^+)}{\varepsilon_s}.
$$
 (36)

240 Substituting (31) into the electron current equation (23), we obtain

Fig. 7. Electrostatic potential.

YJCPH 668
ARTICLE IN PRESS No. of Pages 26, DTD=5.0.1

23 October 2004; Disk Used

R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx 11

$$
\mathbf{J}_{\mathbf{n}} = -q\mu_{\mathbf{n}}n\nabla(\phi + \phi_{\mathbf{qn}}) + qD_{\mathbf{n}}\nabla\left[n_{i}\exp\left(\frac{\phi + \phi_{\mathbf{qn}}}{V_{\mathbf{T}}}\right)u\right]
$$
(37)
\n
$$
= -q\mu_{\mathbf{n}}n\nabla(\phi + \phi_{\mathbf{qn}}) + q\frac{D_{\mathbf{n}}}{V_{\mathbf{T}}}\left[n_{i}\exp\left(\frac{\phi + \phi_{\mathbf{qn}}}{V_{\mathbf{T}}}\right)u\right]\nabla(\phi + \phi_{\mathbf{qn}}) + qD_{\mathbf{n}}\left[n_{i}\exp\left(\frac{\phi + \phi_{\mathbf{qn}}}{V_{\mathbf{T}}}\right)\right]\nabla u
$$
\n
$$
= qD_{\mathbf{n}}n_{i}\exp\left(\frac{\phi + \phi_{\mathbf{qn}}}{V_{\mathbf{T}}}\right)\nabla u,
$$
\n(38)

243 which defines the generalized quasi-Fermi potential as in

$$
\mathbf{J}_n = -q\mu_n n \nabla \varphi_n,\tag{39}
$$

247 with the quantum correction in electron concentration. Boundary conditions for this potential can be easily 248 specified. Similar expressions also exist for hole.

249 For the energy fluxes, we rewrite (9) more precisely as

$$
\mathbf{S}_{\mathrm{n}} = \frac{5\mathbf{J}_{\mathrm{n}}}{-2q}k_{\mathrm{B}}T_{\mathrm{n}} - \kappa_{\mathrm{n}}\nabla T_{\mathrm{n}} + \frac{\mathbf{J}_{\mathrm{n}}}{-q}\left(\frac{1}{2}m_{\mathrm{n}}^{*}|\mathbf{v}_{\mathrm{n}}|^{2}\right).
$$
\n(40)

252 Substituting (16), (29), and (39) into this equation, we have

$$
\mathbf{S}_{n} = \frac{5\mathbf{J}_{n}}{-2q} k_{\text{B}}g_{n} \exp\left(\frac{5\varphi_{n}}{4V_{\text{T}}}\right) - \kappa_{n} \left[\exp\left(\frac{5\varphi_{n}}{4V_{\text{T}}}\right) \nabla g_{n} + \frac{5}{4V_{\text{T}}} g_{n} \exp\left(\frac{5\varphi_{n}}{4V_{\text{T}}}\right) \nabla \varphi_{n}\right] + \frac{\mathbf{J}_{n}}{-q} \left(\frac{1}{2} m_{n}^{*} |\mathbf{v}_{n}|^{2}\right)
$$

= $-\kappa_{n} \exp\left(\frac{5\varphi_{n}}{4V_{\text{T}}}\right) \nabla g_{n} + \frac{\mathbf{J}_{n}}{-q} \left(\frac{1}{2} m_{n}^{*} |\mathbf{v}_{n}|^{2}\right).$ (41)

Fig. 8. Electron concentration.

12 R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx

255 Hence, we obtain the following self-adjoint form

$$
\nabla \cdot \left(\kappa_n \exp \left(\frac{5\varphi_n}{4V_T} \right) \nabla g_n \right) = R_n(g_n), \tag{42}
$$

258 where

1

$$
R_{\mathbf{n}}(g_{\mathbf{n}}) = n\left(\frac{\omega_{\mathbf{n}} - \omega_{0}}{\tau_{\mathbf{n}\omega}}\right) - \mathbf{J}_{\mathbf{n}} \cdot \mathbf{E} - \frac{1}{q} \nabla \cdot \left(\frac{1}{2} m_{\mathbf{n}}^{*} \frac{|\mathbf{J}_{\mathbf{n}}|^{2}}{q^{2} n^{2}} \mathbf{J}_{\mathbf{n}}\right).
$$
\n(43)

261 We also have a similar equation for hole.

262 Our new model for both DG and ET equations with the seven state variables ϕ , u, v, ζ_n , ζ_p , g_n , and g_p 263 and their associated boundary conditions (BCs) is re-organized as follows:

$$
\Delta \phi = F(\phi, u, v, \zeta_n, \zeta_p),
$$
\n
$$
\frac{1}{q} \nabla \cdot \mathbf{J}_n = R(\phi, u, v, \zeta_n, \zeta_p),
$$
\n(44)

$$
\frac{1}{q}\nabla \cdot \mathbf{J}_{\mathrm{p}} = -R(\phi, u, v, \zeta_{\mathrm{n}}, \zeta_{\mathrm{p}}),\tag{46}
$$

$$
\Delta \zeta_n = Z_n(\phi, u, v, \zeta_n, \zeta_p),\tag{47}
$$

Fig. 9. Hole concentration.

YJCPH 668
ARTICLE IN PRESS No. of Pages 26, DTD=5.0.1

R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx 13

$$
\Delta \zeta_p = Z_p(\phi, u, v, \zeta_n, \zeta_p),\tag{48}
$$

$$
\nabla \cdot \mathbf{G}_n = R_n(g_n),\tag{49}
$$

$$
\nabla \cdot \mathbf{G}_{\mathbf{p}} = R_{\mathbf{p}}(g_{\mathbf{p}}),\tag{50}
$$

285 where

$$
F(\phi, u, v, \zeta_n, \zeta_p) = \frac{qn_i}{\varepsilon_s} \left[u \exp\left(\frac{\phi + \phi_{qn}}{V_T}\right) - v \exp\left(\frac{-\phi - \phi_{qp}}{V_T}\right) \right] + \frac{q(N_A^- - N_D^+)}{\varepsilon_s},\tag{51}
$$

$$
\mathbf{J}_{n} = +qD_{n}n_{i} \exp\left(\frac{\phi + \phi_{qn}}{V_{T}}\right) \nabla u,
$$
\n
$$
(-\phi - \phi_{qn})
$$
\n(52)

$$
\mathbf{J}_{\mathrm{p}} = -qD_{\mathrm{p}}n_{\mathrm{i}}\exp\left(\frac{-\phi - \phi_{\mathrm{qp}}}{V_{\mathrm{T}}}\right)\nabla v,\tag{53}
$$

$$
R(\phi, u, v, \zeta_n, \zeta_p) = \frac{n_1^2 \left[uv \exp\left(\frac{\phi_{qn} - \phi_{qp}}{V_T}\right) - 1 \right]}{\tau_n^0 \left[n_1 v \exp\left(\frac{-\phi - \phi_{qp}}{V_T}\right) + p_T \right] + \tau_p^0 \left[n_1 u \exp\left(\frac{\phi + \phi_{qp}}{V_T}\right) + n_T \right]},
$$
(54)

$$
Z_{n}(\phi, u, v, \zeta_{n}, \zeta_{p}) = \frac{\zeta_{n}}{2b_{n}} \left[V_{T} \ln(\zeta_{n}^{2}) - V_{T} \ln(u n_{i}) - \phi \right],
$$
\n(55)

Fig. 10. Electron temperature.

YJCPH 668
ARTICLE IN PRESS No. of Pages 26, DTD=5.0.1

14 R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx

$$
Z_{\mathbf{p}}(\phi, u, v, \zeta_{\mathbf{n}}, \zeta_{\mathbf{p}}) = -\frac{\zeta_{\mathbf{p}}}{2b_{\mathbf{p}}} \left[-V_{\mathbf{T}} \ln(\zeta_{\mathbf{p}}^2) + V_{\mathbf{T}} \ln(vn_{\mathbf{i}}) - \phi \right],\tag{56}
$$

$$
\phi_{qn} = V_T \ln(\zeta_n^2) - V_T \ln(un_i) - \phi, \qquad (57)
$$

$$
\phi_{\rm qp} = -V_{\rm T} \ln(\zeta_{\rm p}^2) + V_{\rm T} \ln(vn_{\rm i}) - \phi,\tag{58}
$$

$$
\mathbf{G}_{n} = \kappa_{n} \exp\left(\frac{5\varphi_{n}}{4V_{T}}\right) \nabla g_{n},\tag{59}
$$

$$
\mathbf{G}_{\mathrm{p}} = \kappa_{\mathrm{p}} \exp\left(-\frac{5\varphi_{\mathrm{p}}}{4V_{\mathrm{T}}}\right) \nabla g_{\mathrm{p}},\tag{60}
$$

$$
R_{n}(g_{n}) = n\left(\frac{\omega_{n} - \omega_{0}}{\tau_{n\omega}}\right) - \mathbf{J}_{n} \cdot \mathbf{E} - \frac{1}{q} \nabla \cdot \left(\frac{1}{2} m_{n}^{*} \frac{|\mathbf{J}_{n}|^{2}}{q^{2} n^{2}} \mathbf{J}_{n}\right),
$$
\n(61)

$$
R_{\mathbf{p}}(g_{\mathbf{p}}) = p\left(\frac{\omega_{\mathbf{p}} - \omega_{0}}{\tau_{\mathbf{p}\omega}}\right) - \mathbf{J}_{\mathbf{p}} \cdot \mathbf{E} + \frac{1}{q} \nabla \cdot \left(\frac{1}{2} m_{\mathbf{p}}^{*} \frac{|\mathbf{J}_{\mathbf{p}}|^{2}}{q^{2} p^{2}} \mathbf{J}_{\mathbf{p}}\right).
$$
\n(62)

315 The boundary conditions are changed accordingly to

Fig. 11. Hole temperature.

ARTICLE IN PRESS

$$
\phi = V_0 + V_b,
$$

\n
$$
u = \exp\left(\frac{-V_0}{V_T}\right),
$$

\n
$$
v = \exp\left(\frac{V_0}{V_T}\right),
$$

\n
$$
\zeta_n^2 = \frac{1}{2} \left[(N_D^+ - N_A^-) + \sqrt{(N_D^+ - N_A^-)^2 + 4n_i^2} \right],
$$

\n
$$
\zeta_p = n_i / \zeta_n,
$$

\n
$$
g_n = \frac{300}{\exp\left(\frac{5V_0}{4V_T}\right)},
$$

\n
$$
g_p = \frac{300}{\exp\left(-\frac{5V_0}{4V_T}\right)} \quad \text{on } \partial\Omega_D
$$

318 and

$$
\frac{\partial \phi}{\partial n} = \frac{\partial u}{\partial n} = \frac{\partial v}{\partial n} = \frac{\partial \zeta_n}{\partial n} = \frac{\partial \zeta_p}{\partial n} = \frac{\partial g_n}{\partial n} = \frac{\partial g_p}{\partial n} = 0 \text{ on } \partial \Omega_N,
$$

321 where V_{O} denotes the applied voltage and V_{b} represents the built-in potential. Here, $\Omega \subset \mathbb{R}^2$ denotes the 322 bounded domain of the silicon. The boundary $\partial\Omega = \partial\Omega_D \cup \partial\Omega_N$ is piecewise smooth consisting of Dirichlet

323 $\partial\Omega_D$ and Neumann $\partial\Omega_N$ parts. The Dirichlet part corresponds to the ohmic contacts on the device. Note

Fig. 12. Electron quantum potential.

16 R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx

324 that the above Neumann BCs for ζ_n and ζ_p do not hold on the entire $\partial\Omega_N$ excluding the oxide interface at 325 which a zero Dirichlet BC is imposed. As mentioned in [8], the quantum potentials would have to be infinite 326 at the interface to force the carrier densities to exactly zero there. Thus, a suitable constraint on the values 327 of the quantum potentials at the interface is also not available. A small but non-zero value of the carrier 328 densities is instead used in that paper. Our implementation of such non-exact zero Dirichlet BC at the inter-329 face will be specified in Section 5.

330 It should be noted that effective approximation of the gradient of current densities in formulas (61) and 331 (62) is in general very difficult to acquire. Simplified models for these formulas based on physical consid-332 eration are possible. For example, by assuming that the drift energy is only a small part of the total kinetic 333 energy [10], (61) and (62) can be reduced to

$$
R_{n}(g_{n}) = n\left(\frac{\omega_{n} - \omega_{0}}{\tau_{n\omega}}\right) - \mathbf{J}_{n} \cdot \mathbf{E},
$$

$$
R_{p}(g_{p}) = p\left(\frac{\omega_{p} - \omega_{0}}{\tau_{p\omega}}\right) - \mathbf{J}_{p} \cdot \mathbf{E},
$$

336 which will be used in our numerical simulations.

337 Remark 3.1. As observed in [5], the SRH generation-recombination model (18) should be modified for the

338 DG model since this standard expression will produce spurious generation and recombination near the

339 oxide barrier. We thus consider here the modified SRH (MSRH) proposed in [5] and extend it into the self-340 adjoint context as follows:

Fig. 13. Hole quantum potential.

ARTICLE IN PRESS

R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx 17

$$
\dfrac{np-n_{eq}p_{eq}}{\tau_n^0\left(p+\sqrt{n_{eq}p_{eq}}\exp\left(\frac{\epsilon_i-\epsilon_i}{k_BT}\right)\right)+\tau_p^0\left(n+\sqrt{n_{eq}p_{eq}}\exp\left(\frac{\epsilon_i-\epsilon_i}{k_BT}\right)\right)}\\=\dfrac{n_i^2uv\exp\left(\frac{\phi_{qn}-\phi_{qp}}{V_T}\right)-n_{eq}p_{eq}}{\tau_n^0\left[n_i v\exp\left(\frac{-\phi-\phi_{qp}}{V_T}\right)+\sqrt{n_{eq}p_{eq}}\exp\left(\frac{\epsilon_i-\epsilon_i}{k_BT_L}\right)\right]+\tau_p^0\left[n_i u\exp\left(\frac{\phi+\phi_{qp}}{V_T}\right)+\sqrt{n_{eq}p_{eq}}\exp\left(\frac{\epsilon_i-\epsilon_i}{k_BT_L}\right)\right]}.
$$

343 Note that the term n_i^2 in (18) is replaced by $n_{eq}p_{eq}$ in this MSRH model where ε_t and ε_i are the trapped and 344 intrinsic energies. The quantities n_{eq} and p_{eq} are the spatially dependent equilibrium densities obtained from 345 a separate numerical solution of the same DG problem, but with all voltages and R set to zero. Following 346 that paper, we choose $\tau_n^0 = \tau_p^0 = 10^{-8}$ s with $\varepsilon_t = \varepsilon_i$ in our simulation. A comparison of numerical results 347 based on both SRH and MSRH models will be given in Section 5.

348 **Remark 3.2.** For simplicity, we use fixed mobilities of $\mu_n = 1500 \text{ cm}^2/\text{V s}$ and $\mu_p = 500 \text{ cm}^2/\text{V s}$ which are 349 roughly equal to the intrinsic values at room temperature for silicon as considered in [8]. In our numerical 350 experiences in [11,12], the field-dependent mobility model of the Caughey–Thomas expression still can be 351 used in the DGET simulation.

352 Remark 3.3. The above self-adjoint formulation is based on Maxwell–Boltzmann statistics. However, it is 353 unclear to us whether the self-adjointness can also be derived for the case of Fermi–Dirac statistics which is 354 more exact but more complicated to implement. Evidently, this issue deserves further investigation in the 355 future.

Fig. 14. Electron density profile perpendicular to the inverted channel.

ARTICLE IN PRESS

18 R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx

356 4. An adaptive finite element algorithm for the DGET model

357 The main ingredients of the algorithm solving the DGET model are adaptive finite element approxima-358 tion of the model, node-by-node and monotone iterative solution of the resulting nonlinear algebraic sys-359 tems, and Gummel's iteration consecutively on the PDEs as described in [11] for the ET model. For the sake 360 of clearness, we briefly illustrate the algorithm and refer to [11,12] for more details on the adaptive finite 361 element formulation, monotone convergence analysis, and practical implementation issues.

362 Here, we use the notation l as Gummel's (outer) iteration index and m as the monotone (inner) iteration 363 index.

- 364 Step 1. Initial mesh: create a coarse and structured mesh for which the number of nodes can be chosen as 365 small as possible.
	- 366 Step 2. Preprocessing: see [11].
	- 367 Step 3. Gummel and Monotone iterations on (44)–(48).

368 *Step 3.0.* Set $l: = 0$

369 Step 3.1. Solve the potential equation in (44).

370 Step 3.1.1. Set $m: = 0$ and set the initial guess

$$
\phi_j^{(m)} = \begin{cases} \widetilde{\phi_j} \text{ or } \widehat{\phi_j} & \text{if } l = 0, \\ \phi_j^{(l)} & \text{otherwise,} \end{cases} \text{ for all } (x_j, y_j) \in \overline{\Omega}^h
$$

373 where ϕ_j and $\hat{\phi}_j$ are constant values that can be easily verified to be an upper and lower solution of ϕ ,

;

- 374 respectively, and $\overline{\Omega}^h$ denotes the set of mesh points on the closure of the domain.
	- 375 Step 3.1.2 If $l = 0$, set $u^{(l)}$ and $v^{(l)}$ by the charge neutrality condition.

Fig. 15. Electron current density (ET).

R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx 19

376 *Step 3.1.3*. Compute $\phi_j^{(m+1)}$ by solving the discrete potential system of (44)

$$
\begin{cases}\n\xi_j \phi_j^{(m+1)} + \gamma_j(\phi) \phi_j^{(m+1)} = \sum_{k \in V(j)} \xi_k \phi_k^{(m)} - F(\phi_j^{(m)}, u_j^{(l)}, v_j^{(l)}, \zeta_n^{(l)}) + \gamma_j(\phi) \phi_j^{(m)}, \quad \forall (x_j, y_j) \in \Omega^h, \\
\phi_j^{(m+1)} = V_0 + V_b, \quad \forall (x_j, y_j) \in \partial \Omega_D^h, \\
\frac{\partial \phi_j^{(m+1)}}{\partial n} = 0, \quad \forall (x_j, y_j) \in \partial \Omega_N^h,\n\end{cases}
$$

380 where

$$
\gamma_j(\phi) = \max \left\{ \frac{\partial F(\phi_j)}{\partial \phi}; \hat{\phi}_j \leq \phi_j \leq \tilde{\phi}_j \right\},\
$$

384 ξ_k are the matrix elements of the discretization, and Ω^h , $\partial \Omega^h$, and $\partial \Omega^h$ represent the sets of mesh points in 385 the interior, Dirichlet part, and Neumann part of the domain, respectively.

Step 3.1.4. Set $\phi_j^{(m)} := \phi_j^{(m+1)}$ $\forall j$ and $m: = m + 1$. Go to Step 3.1.3 until the stopping criteria of the inner iteration are satisfied.

389 Step 3.1.5. Set
$$
\phi_j^{(l+1)} := \phi_j^{(m+1)} \ \forall j
$$
.

Step 3.2. Solve the electron continuity equation (45). Step 3.2.1. Set $m = 0$ and set the initial guess

 $u_j^{(m)} = \begin{cases} \widetilde{u}_j \text{ or } \widehat{u}_j & \text{if } l = 0, \\ u_j^{(l)} & \text{otherwise,} \end{cases}$ ϵ for all $(x_j, y_j) \in \overline{\Omega}^h$,

Fig. 16. Electron current density (DG).

 $\hspace{1.6cm} (64)$

 (63)

ARTICLE IN PRESS

20 **R.-C.** Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx

- 394 where \tilde{u}_i and \hat{u}_i are constant values for all $(x_i, y_i) \in \overline{\Omega}^h$ that can be easily verified to be an upper and lower 395 solution of u , respectively.
	- Step 3.2.2. Compute $u_j^{(m+1)}$ by solving the discrete electron system of (45).

Step 3.2.3. Set $u_j^{(m)} := u_j^{(m+1)}$ $\forall j$ and $m: = m + 1$. Go to Step 3.2.2 until the stopping criteria of the inner iteration are satisfied.

400 Step 3.2.4. Set $u_j^{(l+1)} := u_j^{(m+1)} \ \forall j$.

- 401 Step 3.3. Solve the hole continuity equation (46) similarly to that in Step 3.2.
- 402 Step 3.4. Solve the DG equation (47).

Step 3.4.1. Set $m: = 0$ and set the initial guess

$$
\left[\zeta_n\right]_j^{(m)} = \begin{cases} \left[\widetilde{\zeta_n}\right]_j \text{ or } \left[\widehat{\zeta_n}\right]_j & \text{if } l = 0, \\ \left[\zeta_n\right]_j^{(l)} & \text{otherwise,} \end{cases} \quad \text{for all } (x_j, y_j) \in \overline{\Omega}^h,
$$

406 where $[\zeta_n]_j \approx \zeta_n(x_j, y_j)$ and $[\widetilde{\zeta_n]_j}$ and $[\widetilde{\zeta_n]_j}$ are constant values for all $(x_j, y_j) \in \overline{\Omega}^h$ that can be easily verified to 407 be an upper and lower solution of ζ_n , respectively.

Step 3.4.2. Compute $[\zeta_n]_{j}^{(m+1)}$ by solving the discrete system of (47).

Step 3.4.3. Set $\left[\zeta_n\right]_j^{(m)} := \left[\zeta_n\right]_j^{(m+1)}$ $\forall j$ and $m: = m+1$. Go to Step 3.4.2 until the stopping criteria of the inner iteration are satisfied.

412 Step 3.4.4. Set $[\zeta_n]_j^{(l+1)} := [\zeta_n]_j^{(m+1)} \ \forall j.$

413 Step 3.5. Solve the DG (48) similarly to that in Step 3.4.

414 *Step 3.6*. Update $[\phi_{qn}]_j^{(l+1)}$ and $[\phi_{qp}]_j^{(l+1)}$ by the Eqs. (57) and (58).

416 $\frac{4}{3}$ Step 3.7. Set $l = l + 1$ and go to Step 3.1 until the stopping criteria of the outer iteration are satisfied. 417 Step 4. Monotone Iteration on (49) and (50).

Fig. 17. Electron current density (DGET).

ARTICLE IN PRESS

R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx 21

418 Step 4.1. Solve the energy equation (49) for g_n similarly to that in Step 3.2.

42 θ 419 *Step 4.2.* Solve the energy equation (50) for g_p similarly to that in Step 3.2. 421 *Step 5.* Error estimation: See [11].

Step 5. Error estimation: See [11].

422 Step 6. Refinement: See [11]

423 Step 7. Postprocessing: All computed solutions are then postprocessed for further analysis of physical 424 phenomena.

425

Note that, in each one of Steps $3.1-3.5$, 4.1 , and 4.2 , a Jacobi (node-by-node) type of solution is per-427 formed for the corresponding discrete system (63), for example, in which the monotone parameters (64) 428 can be easily obtained by means of lower and upper solutions. Two important factors that guarantee a glo-429 bal convergence with this kind of simple solutions as initial guesses are the diagonally dominant property of 430 the matrices due to the self-adjoint formulation and the monotonicity of the parameters by the special non-431 linearity of the formulation. The diagonally dominant property for (44)–(50) can proved in exactly the same 432 manner as that given in [11,12]. It can also be easily shown that each one of the nonlinear functionals in 433 (44)–(50) is monotone in its respective state variable. It is thus a straightforward generalization from our 434 previous theoretical analysis that all the nonlinear algebraic systems generated by this algorithm preserve

435 these two factors. We thus summarize these important results in the following theorem.

436 **Theorem.** For each one of the PDEs (44) – (50) with associated boundary conditions, the matrices resulting to

437 the adaptive finite element approximation are diagonally dominant. Moreover, starting with suitable lower and

438 upper solutions of the corresponding PDE, the Jacobi iteration in each of Steps 3.1–3.5, 4.1, and 4.2 generates

439 a pair of lower and upper sequences which converge monotonically to the exact solution of the nonlinear

440 algebraic system of equations of that PDE.

Fig. 18. Hole temperature (with the standard SRH model (18)).

ARTICLE IN PRESS

22 R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx

441 5. Numerical examples

442 To demonstrate the effectiveness and accuracy of the DGET model, several numerical studies have been 443 made for sample diode and MOSFET device structures. A benchmark device, namely, an abrupt n^+ – n^+ 444 silicon diode is first used to verify our methods and formulation with the results reported in literature. 445 Numerical experiments are performed first on a 600 nm silicon diode at 300 K with $n^+ = 5.0 \times 10^{17}$ cm⁻³ 446 and $n = 2.0 \times 10^{15}$ cm⁻³. The length of the *n*-region is approximately 400 nm. The steady state results 447 for this problem are illustrated by the dotted and solid curves with respective to the DGET and ET models 448 in Figs. 1(a)–(d) where the applied voltage V_O is taken as 2.0 V. The dotted curve coincides with the solid 449 curve. This represents that the new model can be applied to devices with larger size, i.e., where the QM 450 effects are negligible. These results agree also very well with that previously reported in the literature 451 [2,14,17,31].

452 To verify QM effects with our model, we then reduce the scale down to two cases. Case (1) is a 120 nm 453 silicon diode with $n^+ = 5.0 \times 10^{18}$ cm⁻³ and $n = 2.0 \times 10^{15}$ cm⁻³. The length of the *n*-region is approximately 454 80 nm. The applied voltage V_{Ω} is taken as 1.2 V. Case (2) is a 30 nm silicon diode with $n^+ = 5.0 \times 10^{19}$ cm⁻³ 455 and $n = 2.0 \times 10^{15}$ cm⁻³. The length of the *n*-region is approximately 20 nm. The applied voltage V_{O} is ta-456 ken as 0.8 V. Figs. 2 and 3 show the significant change of the electron density predicted by the new model 457 but for the electron temperature the change is not very significant. The maximal temperatures of ET and 458 DGET models are $T = 3423$ K and $T = 3309$ K, respectively. The corresponding thermal energies are 459 $E_{\text{th}} = \frac{3}{2} k_{\text{B}} T = 0.442 \text{ eV}$ and $E_{\text{th}} = 0.428 \text{ eV}$. Therefore, the temperature reduced by the QM corrections 460 of the DGET model is very similar to that by the nonparabolicity effects presented in [14]. Fig. 4 shows 461 a visible tendency of the quantum potential $\phi_{\rm on}$ toward a large variation when the channel length is de-462 creased. Here, we scale the figures into the same size for comparison.

Fig. 19. Hole temperature $(R = 0)$.

ARTICLE IN PRESS

R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx 23

463 The second example of our simulation test on the model is a MOSFET device structure which has an 464 elliptical 10^{19} cm⁻³ Gaussian doping profiles in the source and drain regions and 10^{16} cm⁻³ in the p-sub-465 strate region as shown in Fig. 5. The junction depth is 20 nm, the lateral diffusion under gate is 8 nm, the 466 channel length is 34 nm, and the gate oxide thickness is 2 nm. With $V_{\text{BS}} = 0$ V, $V_{\text{DS}} = 1.0$ V and $V_{\text{GS}} = 0.8$ 467 V, Figs. 6–13 present the final adaptive mesh, electrostatic potential, electron concentration, hole concen-468 tration, electron temperature, hole temperature distribution, electron quantum potential, and hole quantum 469 potential, respectively. Across the junction, Figs. 12 and 13 clearly show similar quantum potential profiles 470 as that in Fig. 4 for the 1D diode device. Furthermore, in the direction perpendicular to the interface, a very 471 thin boundary layer of about 6 nm appear in the inversion layer as shown in Figs. 12–17. The boundary 472 layer as shown in Fig. 6 is effectively captured by the a posteriori error estimation with 1-irregular refine-473 ment strategy developed in [11,12,25,26].

474 As mentioned earlier, a suitable constraint on the values of the quantum potentials at the oxide interface 475 is not available. One solution to this lack of quantum potential BCs is to solve the DGET model in the 476 oxide as well as in the adjoining silicon and poly gate. This will allow us to simulate the tunneling effects 477 across the oxide [13]. This issue is not addressed here and will be reported elsewhere in our future works. 478 We do not impose zero Dirichlet BCs for the variables ζ_n and ζ_p exactly at the interface but instead at the 479 grid points in silicon that are very close (about 0.13 nm) to the interface. In effect, these BCs are very similar 480 to that in [8] where a small but non-zero value of the carrier densities is set at the interface. We found that if 481 the BCs are prescribed exactly at the interface, the result of temperature will be very poor although the 482 algorithm is still convergent.

Fig. 20. Channel current for MOSFET, gate voltage $V_{GS} = 0.7, 0.8, 0.9$ V.

ARTICLE IN PRESS

24 R.-C. Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx

483 As noted in Remark 2.2, the quantum corrections are implicitly defined in the energy fluxes (9) and (10) 484 via the carrier densities (19) and (20), the temperature distribution of carriers will not be very accurate as 485 shown in Figs. 10 and 11. More specifically, the temperature peak for electron appears to be near the drain 486 but the peak for hole is in the middle of the channel. We found that the generation-recombination model 487 will influence the hole temperature distribution significantly. If the standard SHR model (54) is used instead 488 of the MSHR model of Remark 3.1, the hole temperature is even much worse as shown in Figs. 18 and 19. 489 To our knowledge, there are no numerical results of quantum corrected carrier temperatures available in 490 the literature to be compared with our results. Evidently, efficient and effective numerical methods for han-491 dling energy fluxes with explicit quantum corrections are needed for future investigations.

If the plane the role is m the means of the channel. We found that the generato-scontinuation model
in influence the lot temperature distribution significantly. If the stundard STR model (SH planed inselect the lot the NS 492 The electron density profile shown in Fig. 14 is a cross section of the 2D profile at the middle point of the 493 interface. The peak of the density is about 1.5 nm away from the interface, which agrees well with that in 494 [7], see also [1]. Fig. 15 is the electron current density computed by the ET model, which clearly shows that 495 the classical density is sharply peaked comparing with the smoothly peaked in Figs. 16 and 17 obtained by 496 the DG and DGET models. The substantial QM effect of transconductance degradation is also evidently 497 displayed in these figures. From these figures, we observe that the carrier temperature provides a mecha-498 nism to increase carrier diffusion as noted in Remark 2.1. This is the main justification to consider DGET 499 instead of DG along.

500 Finally, Fig. 20 shows the simulated I–V curves in which the drain current obtained by the DGET model 501 is about 20–60% below that predicted by the ET model for the gate biases of 0.7, 0.8, and 0.9 V. This result 502 is also in good agreement with that of [8] where a MOSFET with 30 nm gate length and 2 nm gate oxide 503 thickness is considered. Admittedly, this represents a serious decrease in the current drive capability of the 504 device. Note also that the difference of the maximal temperatures between the ET ($T = 3677 \text{ K}$) and DGET 505 ($T = 3649$ K) models is not very significant. The corresponding thermal energies are 0.475 and 0.471 eV. 506 The figure also shows that ET over estimates the current whereas DG under estimates.

507 6. Conclusion

508 A self-adjoint model combining both ET and DG models is proposed here for nanoscale semiconductor 509 devices. This model is capable of describing hot carrier and quantum correction effects.

510 Moreover, due to the self-adjointness and monotonic nonlinearity, the present model enjoys many fav-511 orable mathematical properties such as global convergence with simple initial guesses, highly parallelizable, 512 and fast iterative solution. Numerical convergence is a fundamental issue constantly faced by the practi-513 tioner in device and circuit simulation. This model and monotone iterative methods may offer an alternative 514 in handling the convergence difficulties frequently associated with Newton's methods.

515 Our numerical simulations on diode and MOSFET with the gate length down to 34 nm using the DGET 516 model have been performed and compared with that using the ET model. And the results are shown to be in 517 good agreement with those reported in the literature. It is shown that the $I-V$ characteristics of this short-518 channel device is significantly corrected by the density-gradient equations with current drive reduced by up 519 to 60% comparing with that of the classical model along. Furthermore, a 2D quantum layer, which is only a 520 fraction of the length scale of inversion layer, is also effectively captured by this model with very fine mesh 521 near the interface generated by an adaptive finite element method.

522 Nevertheless, many improvements on our preliminary model can be further studied in future works. For 523 example, the self-adjoint formulation of the present paper is based on Maxwell–Boltzmann statistics. It is 524 however unclear to us whether the self-adjointness can be also derived for the case of Fermi–Dirac statistics 525 which is more exact but more complicated to implement. Moreover, efficient and effective numerical meth-526 ods for handling energy fluxes with explicit quantum corrections are also deserved for future investigations.

527 References

- 528 [1] H. Abebe, E. Cumberbatch, Quantum mechanical effects correction models for inversion charge and $I-V$ characteristics of the 529 MOSFET device, in: Proceedings of the 2003 Nanotechnology Conference, vol. 2, 2003, p
- 529 MOSFET device, in: Proceedings of the 2003 Nanotechnology Conference, vol. 2, 2003, pp. 218–221. 530 [2] N.R. Aluru, A. Raefsky, P.M. Pinsky, K.H. Law, R.J.G. Goossens, R.W. Dutton, A finite element formulation for the hydrodynamic semiconductor device equations, Comput. Methods Appl. Mech. Engrg. 107 (1993) 269.
- TSR. Altar, A. K. Resear, J. K. H. R. H. H. R. N. D. Gowson, R. W. Drive, A. R. C. Const. Straiter, and the constrained by the constrained by the constrained by N. Altar, N. E. N. Strait constrained by N. Altar, N. Strait 532 hydrodynamic semiconductor device equations, Comput. Methods Appl. Mech. Engrg. 107 (1993) 269.
532 [3] M.G. Ancona, G.J. Iafrate, Quantum correction to the equation of state of an electron gas in a semicor 532 [3] M.G. Ancona, G.J. Iafrate, Quantum correction to the equation of state of an electron gas in a semiconductor, Phys. Rev. B 39 33 (1989) 9536.
534 [4] M.G. Ancor
- 534 [4] M.G. Ancona, H.F. Tiersten, Macroscopic physics of the silicon inversion layer, Phys. Rev. B 35 (1987) 7959.
- 535 [5] M.G. Ancona, Z. Yu, R.W. Dutton, P.J.V. Voorde, M. Cao, D. Vook, Density-gradient analysis of MOS tunneling, IEEE Trans. 36 Electron. Dev. 47 (2000) 2310.
537 [6] Y. Apanovich, E. Lyumkis, B.
- 537 [6] Y. Apanovich, E. Lyumkis, B. Polsky, A. Shur, P. Blakey, Steady-state and transient analysis of submicron devices using energy 538 balance and simplified hydrodynamic models, IEEE Trans. CAD 13 (1994) 702.
539 [7] A. Asenov, A.R. Brown, J.R. Watling, The use of quantum potentials for confin
- 539 [7] A. Asenov, A.R. Brown, J.R. Watling, The use of quantum potentials for confinement in semiconductor devices, Model. Simul. 40 Microstruct. (MSM²002) (2002) 490.
541 [8] B.A. Biegel, M.G. Ancona, C.S. Ra
- 541 [8] B.A. Biegel, M.G. Ancona, C.S. Rafferty, Z. Yu, Efficient multi-dimensional simulation of quantum confinement effects in advanced MOS devices, NAS Tech. Report NAS-04-008, 2004. 42 advanced MOS devices, NAS Tech. Report NAS-04-008, 2004.
543 [9] B.A. Biegel, J.D. Plummer, Comparison of self-consistency itera
- 543 [9] B.A. Biegel, J.D. Plummer, Comparison of self-consistency iteration options for the Wigner function method of quantum device simulation. Phys. Rev. B 54 (1996) 8070. 44 simulation, Phys. Rev. B 54 (1996) 8070.
545 (101 D. Chang. J.G. Fossum. Simplified en
- 545 [10] D. Chang, J.G. Fossum, Simplified energy-balance model for pragmatic multi-dimensional device simulation, Solid-State 546 Electron. 41 (1997) 1795.
- 547 [11] R.-C. Chen, J.-L. Liu, An iterative method for adaptive finite element solutions of an energy transport model of semiconductor 548 devices, J. Comput. Phys. 189 (2003) 579.
- 549 [12] R.-C. Chen, J.-L. Liu, Monotone iterative methods for the adaptive finite element solution of semiconductor equations, J. 550 Comput. Appl. Math. 159 (2003) 341.
- 551 [13] C.-H. Choi, Z. Yu, R.W. Dutton, Modelling of MOS scaling with emphasis on gate tunnelling and source/drain resistance, Superlattices Microstruct. 27 (2000) 191.
- 553 [14] P. Degond, A. Jüngel, P. Pietra, Numerical discretization of energy-transport models for semiconductors with non-parabolic band structure, SIAM Sci. Comput. 22 (2000) 986. 554 band structure, SIAM Sci. Comput. 22 (2000) 986.
- 555 [15] D.K. Ferry, J.-R. Zhou, Form of the quantum potential for use in hydrodynamic equations for semiconductor device modeling, 556 Phys. Rev. B 48 (1993) 7944.
- 557 [16] C.L. Gardner, The quantum hydrodynamic model for semiconductor devices, SIAM J. Appl. Math. 54 (1994) 409.
- 558 [17] C.L. Gardner, J.W. Jerome, D.J. Rose, Numerical methods for the hydrodynamic device model: subsonic flow, IEEE Trans. CAD 8 (1989) 501.
- 560 [18] H.L. Grubin, J.P. Kreskovsky, Quantum moment balance equations and resonant tunnelling structures, Solid-State Electron. 32 (1989) 1701.
- 562 [19] W. Hänsch, T. Vogelsang, R. Kircher, M. Orlowski, Carrier transport near the Si/SiO₂ interface of a MOSFET, Solid-State 563 Electron. 32 (1989) 839.
- 564 [20] T. Höhr, A. Schenk, A. Wettstein, W. Fichtner, On density-gradient modeling of tunneling through insulators, IEICE Trans.
565 Electron. E86-C (2003) 379. Electron. E86-C (2003) 379.
- 566 [21] S. Jallepalli, J. Bude, W.K. Shih, M.R. Pinto, C.M. Maziar, A.F. Tasch Jr., Electron and hole quantization and their impact on 567 deep submicron p- and n-MOSFET characteristics, IEEE Trans. Electron Devices 44 (1997) 297.
- 568 [22] J.P. Kreskovsky, H.L. Grubin, VLSI Design 3 (2) (1995) 179.
- 569 [23] R. Lake, G. Klimeck, R.C. Bowen, D. Jovanovic, J. Appl. Phys. 81 (1997) 7845.
- 570 [24] Y. Li, J.-L. Liu, S.M. Sze, T.-S. Chao, A new parallel adaptive finite volume method for the numerical simulation of 571 semiconductor devices, Comput. Phys. Commun. 142 (2001) 285.
- 572 [25] J.-L. Liu, On weak residual error estimation, SIAM J. Sci. Comput. 17 (1996) 1249.
- 573 [26] J.-L. Liu, I.-J. Lin, M.-Z. Shih, R.-C. Chen, M.-C. Hsieh, Object oriented programming of adaptive finite element and finite volume methods, Appl. Numer. Math. 21 (1996) 439.
- 575 [27] C. Philippidis, D. Bohm, R.D. Kaye, The Aharonov–Bohm effect and the quantum potential, Il Nuovo Cimento 71B (1982)
76 75 576
- 577 [28] R. Pinnau, A. Unterreiter, The stationary current–voltage characteristics of the quantum drift-diffusion model, SIAM J. Numer.
578 Anal. 37 (1999) 211. Anal. 37 (1999) 211.
- 579 [29] C.S. Rafferty, B. Biegel, Z. Yu, M.G. Ancona, J. Bude, R.W. Dutton, Multi-dimensional quantum effect simulation using a
580 density-gradient model and script-level programming techniques. Proc. SISPAD (1998) 137-1 580 density-gradient model and script-level programming techniques, Proc. SISPAD (1998) 137–140.
- 581 [30] R. Rios, N.D. Arora, C.-L. Huang, N. Khalil, J. Faricelli, L. Gruber, IEDM Technical Digest (1995) 937.

ARTICLE IN PRESS

26 **R.-C.** Chen, J.-L. Liu / Journal of Computational Physics xxx (2004) xxx–xxx

- 582 [31] M. Rudan, F. Odeh, J. White, Numerical solution of the hydrodynamic model for a one-dimensional device, COMPEL 6 (1987) 583
584
- 584 [32] L. Shifren, R. Akis, D.K. Ferry, Correspondence between quantum and classical motion: comparing Bohmian mechanics with a smoothed effective potential approach, Phys. Lett. A 274 (2000) 75.
- 85 smoothed effective potential approach, Phys. Lett. A 274 (2000) 75.
586 [33] M.J. van Dort, P.H. Woerlee, A.J. Walker, A.H. Juffermans, H. Lifl 586 [33] M.J. van Dort, P.H. Woerlee, A.J. Walker, A.H. Juffermans, H. Lifka, A simple model for quantization effects in heavily-doped
- 587 silicon MOSFET's at inversion conditions, IEEE Trans. Electron. Dev. 39 (1992) 932.
588 [34] Z. Yu, R.W. Dutton, R.A. Kiehl, Circuit/device modeling at the quantum level, IEEE 588 [34] Z. Yu, R.W. Dutton, R.A. Kiehl, Circuit/device modeling at the quantum level, IEEE Trans. Electron. Dev. 47 (2000) 1819. 589

M AND THE WORLD'S A NEW YORK CONDUCTION TO THE THERE IS NO THIS CONDUCTION OF THE THEORY OF THE CONDUCTION OF THE